SPECIAL-PURPOSE

Fully-Automatic Multifunction Wafer Mounter-Peeler

RAD-2510F/125a



- Ultra-thin wafer mounting & peeling
 - ■: Built-in BG-Tape peeling unit
- Advanced inline pre-cut system
- ■■■ DBG[™] process capability



BENEFITS

Multi-functional wafer-mounter: ideal for manufacturing ultrathin wafers

Our multifunctional wafer-mounter is ideal for processing of ultra-thin wafers. After back-grinding, the subsequent processes of UV-irradiation, alignment, frame-mounting, and peeling of BG-tape are performed in one single equipment.

In-line compatible with backgrinding systems for DBG™(Dicing Before Grinding) processes

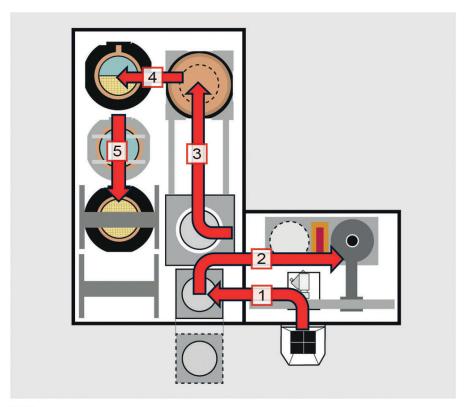
Supports in-line operation with *DISCO's DFG8000* and *DGP8000* series for advanced thin-chip dicing. Minimizes wafer contamination by reducing the wafer-handling steps from 4 times in a stand-alone tool to 2 times with an inline backgrinding system.

Advanced inline pre-cut system

Minimizes waste of material, decreases production cost and reduces tape pitch from 10mm to 2mm.



MOUNTER-PEELER PROCESS-FLOW



- The wafer with BG-tape is taken from loadport and is aligned
- 2 The transfer-arm moves the wafer to the UV-irradiation unit
- The wafer is transferred to the dicing-tape attachment-table for mounting onto a ringframe
- 4 The wafer is moved to the peeling-table to remove the BG-tape
- 5 The finished workpiece is unloaded

BERNOULLI HANDLING SYSTEM



Robot-endeffector*



Alignment table*

LINTEC's market-proven soft-contact Bernoulli hand-ling technology can be integrated into the robot end-effector, the alignment table, and the wafer transfer-arm.

This exceptionally gentle handling method is designed to minimize contact with the wafer after BG tape removal.

^{*}Reference pictures only

SPECIFICATION

Applicable

Standard: **Frame**

Sizes

ø300: SEMI Standard

ø200: DTF2-8-1

Option:

ø150: DTF2-6-1

Loading **Specs**

Standard for single-loader:

FOSB (12")

Double-slot cassette (12")

DBG cassette (12") Open cassette (8")

Options:

Open cassette (6")

In-line specification with

backgrinder

Anti-ESD Specification

Standard:

±100V or less within 10sec after the end of operation*

*Data obtained under LINTEC's measurement conditions

Option:

±50V or less immediately after the end of operation**

**Reference value, measured on mirror wafer

UPH

45 wafers/hour*

*UPH measured under the condition of standard spec and ø300mm full thickness wafer.

UV-irradiation

UV source for BG-tape irradiation can be pre-set in accordance to customers

requirements



STANDARD

- Handling of 300mm / 200mm wafers
- Single load port for FOUP/ FOSB or cassette
- Attachment-table heater function for superior mounting quality
- Built-in BG-tape peeling unit
- Built-in UV-irradiation unit with automated UV intensity control
- Anti-ESD specification: ±100V or less within 10sec after the end of operation



- Handling of 150mm wafers
- Double-pitch slot wafer cassette
- Inline pre-cut unit
- Compatible with DISCO Corporation's Inline equipment series DFG8000 and DGP8000
- Wafer-ID reading function
- Bernoulli Handling System (wafers without BG-tape)
- DBG[™] process capability, incl. circle-shaped robot-endeffector, porous alignment-table and camera-alignment
- Table-cleaning function for alignment-table, attachment-table, peeling-table
- Host communication function (SECS/GEM)
- Vision system (wafer-ID reader & barcode attachment system)



Contact us.
We look forward
to meeting you!



LINTEC Advanced Technologies (Europe) GmbH

European Headquarters:

Konrad-Zuse-Platz 1

81829 Munich

Germany

Phone: +49 (0)89 99 88 50 0

E-mail: sales@linteceurope.com

www.linteceurope.com

